

LISTING OF THE CLAIMS

This listing of claims will replace all prior versions, and listings, of claims in the application:

Claims 1-18 (Canceled)

Claim 19 (Previously Presented)

A substrate processing apparatus operable to supply a fluid to a rotated substrate, the substrate processing apparatus operable to perform prescribed processing and comprising:

a substrate holding/rotating element configured and operable to hold and to rotate said substrate; and

an atmosphere blocking plate configured to be substantially the same in planar shape and size as said substrate holding/rotating element, being rotatably driven and being arranged oppositely and proximately to at least one entire major surface of said substrate when said substrate is held by said substrate holding/rotating element, and formed with a processing solution discharge port and a single inner gas discharge port operable to discharge a processing solution and gas to said surface of said substrate respectively,

a tubular support cylinder supporting said atmosphere blocking plate to be rotatable; and

a cylindrical inner shaft inserted into a hollow portion of said support cylinder; said inner shaft and said support cylinder arranged coaxially with each other, said processing solution discharge port and said single inner gas discharge port arranged on said inner shaft in plan view, said single inner gas discharge port arranged eccentrically to a center of said substrate held by said substrate holding/rotating element so as to be off center relative to said inner shaft; and

an annular outer gas discharge port operable to discharge gas to said surface of said substrate held by said substrate holding/rotating element, the outer gas discharge port formed on said atmosphere blocking plate and interposed between an outer peripheral surface of said inner shaft and an inner peripheral surface of said support cylinder in plan view so as to continuously and annularly enclose said single inner gas discharge port.

Claims 20-22 (Canceled)

Claim 23 (Previously Presented)

The substrate processing apparatus according to claim 19, wherein said outer gas discharge port is so formed on said atmosphere blocking plate such that an arrival position of said gas discharged from said outer gas discharge port is in the vicinity of said intermediate portion between the center and the outer peripheral edge of said surface of said substrate held by said substrate holding/rotating element.

Claims 24-28 (Canceled)